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► **To cite this version:**

Azeddine Tellal, Omar Ziane, Patrice L. Baldeck. Diffraction-limited microfocusing generated by polymer microlines separated by  $1.12 \mu\text{m}$ . Chinese Optics Letters, 2019, 17 (8), pp.082201. 10.3788/COL201917.082201 . hal-02406435

**HAL Id: hal-02406435**

**<https://hal.science/hal-02406435>**

Submitted on 17 Dec 2019

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# Diffraction-limited microfocusing generated by polymer microlines separated by 1.12 $\mu\text{m}$

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Received Month X, XXXX; accepted Month X, XXXX; posted online Month X, XXXX

The diffraction of a dielectric microline pair is optimized by numerical simulations to generate an efficient focusing pattern with a micron-scale footprint. Microlines separated by 1.12  $\mu\text{m}$  are fabricated by two-photon polymerization on a glass substrate, and their diffraction pattern is characterized by 3D wide-field transmission microscopy. A line pair, having a width  $W = 0.4 \mu\text{m}$  and a height  $H = 0.8 \mu\text{m}$ , leads to a diffraction-limited focusing in the visible spectrum. Depending on wavelength, its focal length, lateral resolution, and depth of focus are in the ranges of 0.8-1.3  $\mu\text{m}$ , 0.22-0.44  $\mu\text{m}$ , and 1.7-2.13  $\mu\text{m}$ , respectively. Such microlenses based on the diffraction of only two subwavelength scatterers could be used for the design of miniature optical sensors with micron and sub-micron pixels.

OCIS Codes: 220.0220, 220.3630, 220.4000.

## 1. Introduction

The miniaturization of sensors leads to a continuous trend for downsizing the pixel size. Currently, it is 1.12  $\mu\text{m}$  for visible CMOS sensors, and sub-micron sizes are under development [1]. Below 2  $\mu\text{m}$ , the optical performances of refractive microlenses degrade, and alternative light collection strategies need to be investigated towards wavelength-scale pixels [2-4].

Some micron-scale plasmonics and dielectric lenses based on sub-wavelength structures have been reported [5-7]. They need at least a few periods to generate the spatial phase modulation needed for focusing. Thus, it will be difficult to downscale their sizes in the sub-micron scale.

In our previous work, we have reported on diffraction limited microlenses with sizes in the few micron range. Efficient focusing resulted from the diffraction intensity pattern of parallel metallic nanowires [8-9]. In this work, we report on microfocusing with pairs of parallel polymer lines, separated by 1.12  $\mu\text{m}$ , that do not have ohmic and reflection losses of metals. The line geometry is optimized by 2D numerical simulations to obtain the focusing diffraction pattern. The experimental demonstration is done with their fabrication by two-photon polymerization on a glass substrate, and with their optical characterization by 3D wide-field transmission microscopy.

## 2. Numerical simulations to optimize focusing with polymer microlines

COMSOL multiphysics (radio-frequency module) is used to execute two-dimensional numerical simulations by the finite element method. Reflection artefacts are eliminated by perfectly matched layers. The mesh size is smaller than  $\lambda/10$ .

The diffraction intensity patterns are calculated for pairs of parallel dielectric lines with the rectangular section of width  $W$  and height  $H$  on a dielectric substrate with the same refractive index  $n=1.5$ . Their separation distance (center to center) are set to  $D = 1.12 \mu\text{m}$ . Calculations are done with incident plane waves with TM and TE polarizations, and for monochromatic RGB colors, i.e. wavelengths of 0.60  $\mu\text{m}$ , 0.53  $\mu\text{m}$ , and 0.45  $\mu\text{m}$ .

Typical diffraction intensity patterns are presented in Fig.1. They are calculated for the TE plane wave of wavelength  $\lambda = 0.53 \mu\text{m}$ . The pairs of microlines have a constant width  $W = 0.40 \mu\text{m}$ , and different heights  $H = 0.53 \mu\text{m}$ , 0.80  $\mu\text{m}$  and 1.20  $\mu\text{m}$ . A clear microfocusing pattern is shown in Fig. 1 (b) with the height  $H = 0.80 \mu\text{m}$ . For the smaller height  $H = 0.53 \mu\text{m}$  the diffraction intensity pattern is complex. There is a low-efficiency focusing region with strong sidelobes as shown in Fig. 1 (a). For the larger height  $H = 1.20 \mu\text{m}$  the incident intensity pattern is almost unperturbed by the diffractive structures (Fig. 1 (c)).

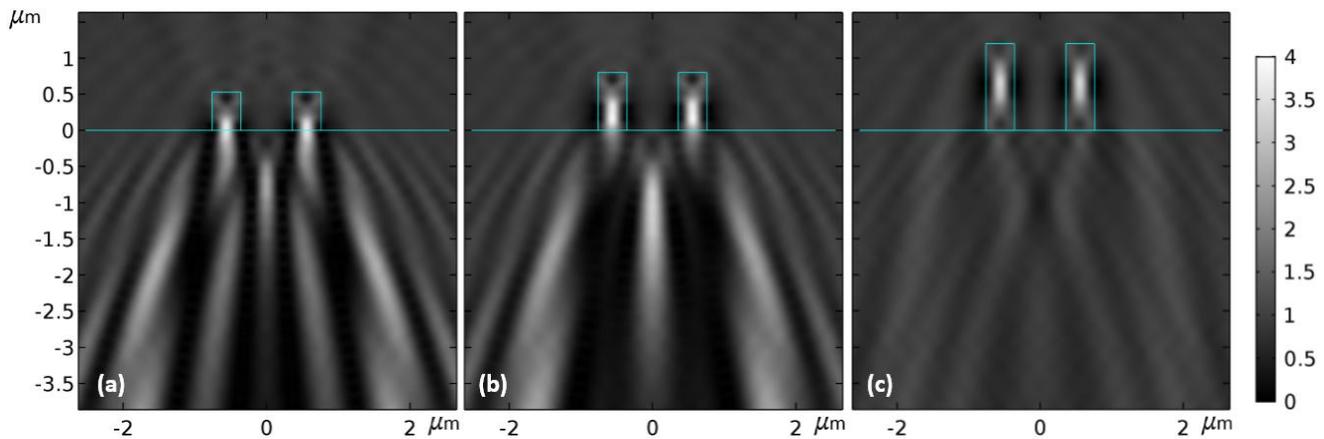


Fig. 1. Diffraction intensity patterns obtained for pairs of dielectric rectangles with different heights  $H = 0.53 \mu\text{m}$ ,  $0.80 \mu\text{m}$ ,  $1.20 \mu\text{m}$  from left to right and width  $W = 0.4 \mu\text{m}$ .

The phase-maps of their diffraction patterns are displayed in Fig. 2. The smaller height accumulates a large phase gradient inside the rectangular structure that leads to nanojet focusing in addition to a small focusing phase modulation between the lines. The larger height accumulates a  $2\pi$  rad phase delay that makes the structure cloaking for the incident plane wave. The height  $H$

$= 0.80 \mu\text{m}$  is optimized to generate the microfocusing pattern because it corresponds to 1) a phase delay of  $\pi$  rad, and therefore a destructive interference below the structure that minimizes the sidelobe intensities, and 2) an efficient focusing spatial phase modulation on the total field that propagates between the structures. Thus, the microfocusing pattern of microlines is obtained only for this optimized height that leads to a  $\pi$ -delay.

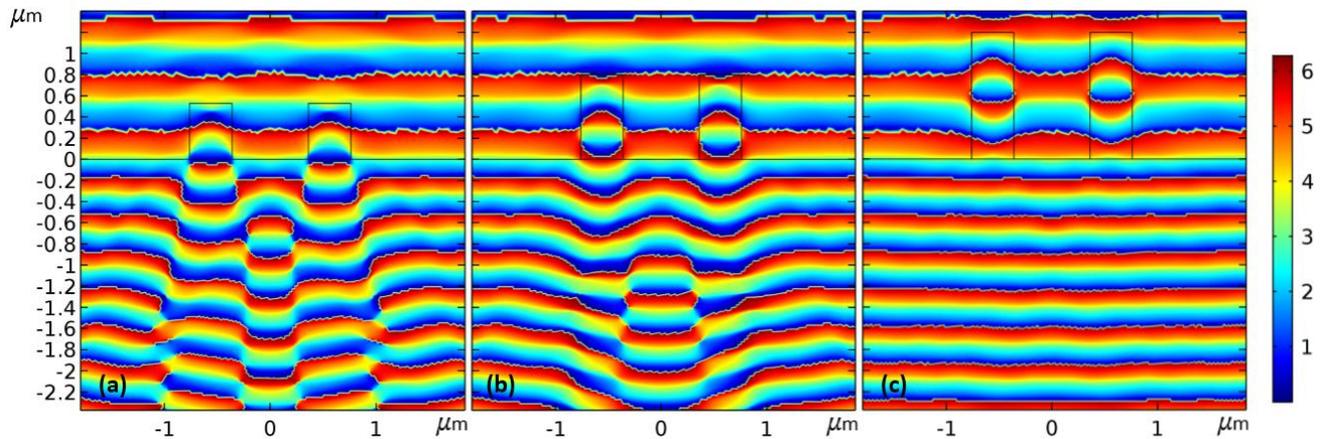


Fig. 2. Phase distribution obtained for pairs of dielectric rectangles with different heights  $H = 0.53 \mu\text{m}$ ,  $0.80 \mu\text{m}$ ,  $1.20 \mu\text{m}$  from left to right and width  $W = 0.40 \mu\text{m}$ .

Next, the optimization of microline widths is needed to obtain the maximum focused power, i.e. the normalized intensity integrated in the focal region ( $I_{\text{max}}/I_0 \cdot \text{FWHM}_x$ ). In the Mie scattering regime, the power scattered by a sub-wavelength size structure is mainly in the forward direction, and it increases with its size. In the case of microfocusing pairs with a fixed separation distance, the maximum width is limited by the minimum space that needs the incident plane wave to propagate freely between the structures. The normalized power that is focalized by structures with  $W$  ranging from  $0.15 \mu\text{m}$  to  $0.50 \mu\text{m}$  is shown in Fig. 3 (black curve). It increases with the structure width, and reaches its maximum for  $W = 0.35 \mu\text{m}$ . For larger widths, the incident wave cannot propagate freely, and the focused power reduces. As shown in Fig. 3, the optimized  $\pi$ -dephasing height increases with  $W$  because of its effective refractive index decrease (Fig. 3 blue curve).

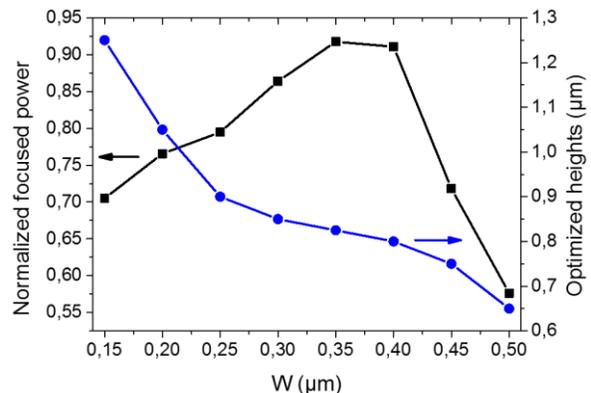


Fig. 3. Variation of the normalized focusing power (black curve with squares), and the optimized  $\pi$ -dephasing rectangle heights (blue curve with disks) with respect to the width.

This type of microfocusing pattern is little sensitive with the polarization, and the wavelengths as shown in Fig. 4. The first and second row correspond to the TE polarization and TM polarization, respectively. The columns correspond to intensity patterns obtained for the RGB wavelengths as indicated.

The microlens characteristics are summarized in Table 1. The focal lengths are in the micron range that is comparable to the separating distance  $D = 1.12 \mu\text{m}$ . The calculated lateral resolutions FWHM<sub>x</sub>, and the depths of focus FWHM<sub>z</sub> are around  $0.3 \mu\text{m}$ , and  $2 \mu\text{m}$ , respectively.

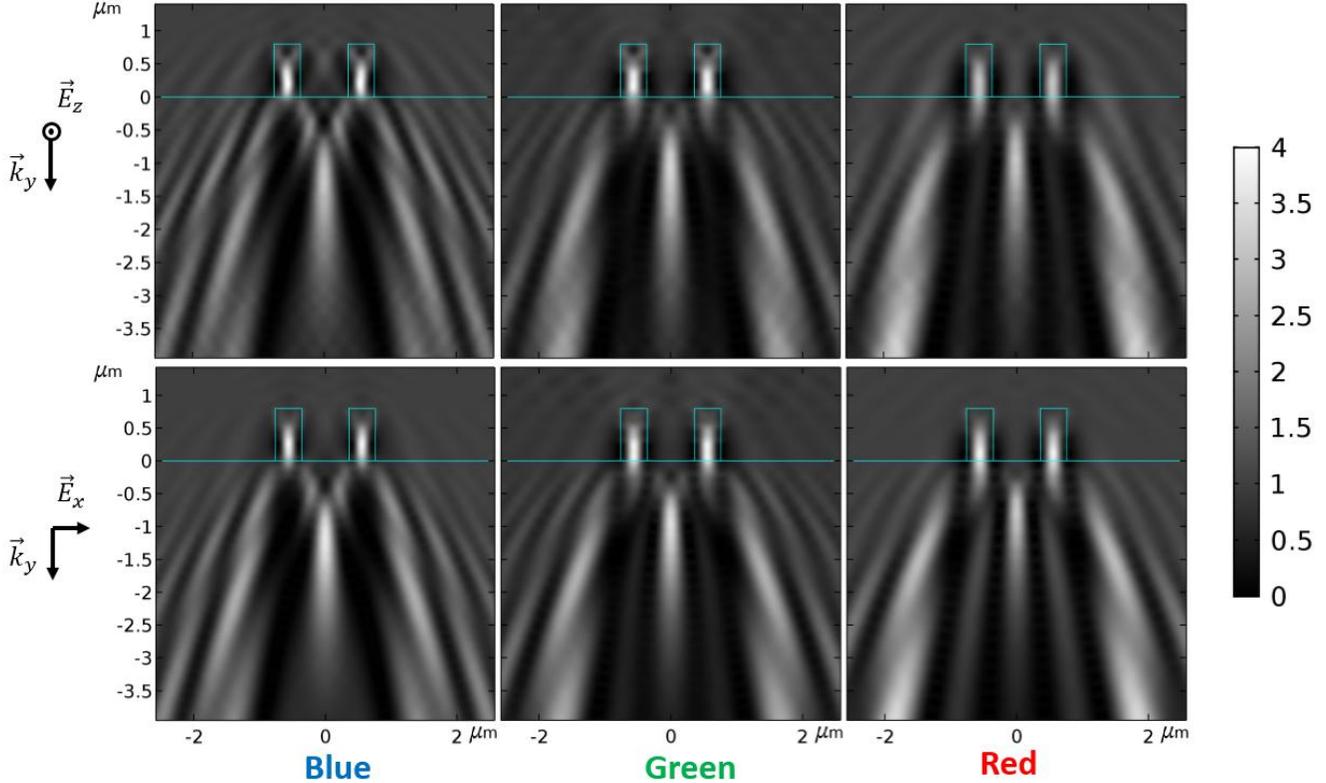


Fig. 4. Diffraction intensity patterns obtained for pairs of dielectric rectangles with optimized dimensions ( $W = 0.40 \mu\text{m}$  and  $H = 0.80 \mu\text{m}$ ). The first and the second rows represent the TE and TM polarizations. From left to right, the columns represent the blue, green and red wavelengths, respectively.

Table 1.

Calculated optical characteristics.  $Z_f$ , FWHM<sub>x</sub>, FWHM<sub>z</sub>, and  $I_{\text{max}}/I_0$  are respectively the focal length, the lateral resolution, the depth of focus, and the normalized intensity at the focal point.

Polarization	Wavelength ( $\mu\text{m}$ )	$Z_f$ ( $\mu\text{m}$ )	FWHM <sub>x</sub> ( $\mu\text{m}$ )	FWHM <sub>z</sub> ( $\mu\text{m}$ )	$I_{\text{max}}/I_0$
TE	Bleu 0.45	1.3	0.28	2.13	3.0
	Green 0.53	1.1	0.27	2.13	3.3
	Red 0.60	1.0	0.27	1.90	3.1
TM	Bleu 0.45	1.2	0.25	1.84	3.6
	Green 0.53	1.0	0.24	1.70	3.5
	Red 0.60	0.8	0.30	1.53	3.1

Further simulations (not shown) indicates that scatterer materials with higher refractive indexes would lead to similar properties with smaller scatterer dimensions. Using substrates with higher refractive indexes would lead to higher lateral resolution with longer focal lengths and depths of focus.

### 3. Experimental demonstration of the diffractive focusing by a pair of parallel lines separated by $D = 1.12 \mu\text{m}$

In the following, we present the experimental demonstration of the microfocusing obtained with parallel polymer lines with a spacing of  $1.12 \mu\text{m}$ . They are fabricated by two-photon polymerization of pentaerythritol triacrylate ( $n \sim 1.5$ ) on a glass

cover slip using the method described in Annex 1. They have a length of  $20 \mu\text{m}$ , and a nominal rectangular cross-section ( $W = 0.40 \mu\text{m}$ , and  $H = 0.80 \mu\text{m}$ ). Cover slip borosilicate substrates with  $170\text{-}\mu\text{m}$  thickness have the advantage to be easily available for high resolution microscopy with immersion objective, and to mimic the dielectric layer that in between the microlens array and the photoactive layer in sensors.

The intensity distributions are measured by widefield transmission microscopy using an inverted microscope (ZeissAxiovert) with an oil immersion objective ( $NA = 1.4$ ), and a Zeiss color camera Axiocam ERC 5. The experimental set-up is shown in Fig. 5. The non-polarized white light is filtered by a

narrow diaphragm ( $< 1\text{mm}$ ) to increase its spatial coherence. A piezo-scanner is used to obtain  $z$ -stacks of RGB images with spacing of  $0.40\ \mu\text{m}$ . The 3D intensity distributions are reconstructed with ImageJ software [11].

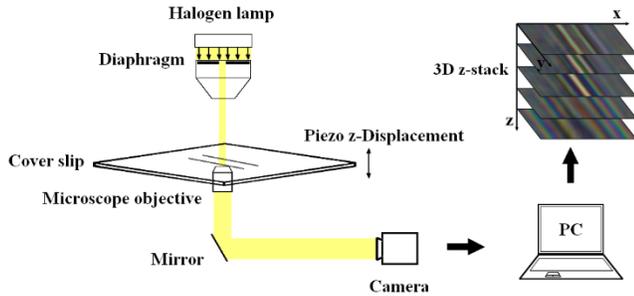


Fig. 5. Schematic of the experimental characterization setup.

The 3D diffraction pattern of microlines separated by  $1.12\ \mu\text{m}$  is shown in Fig. 6. The light is propagating along the  $z$  axis. On the color 3D view (Fig. 6 a), one can clearly distinguish the parallel lines that corresponds to the light getting out of the polymer lines at  $z=0$ , and a white spot at around  $z \approx 1\ \mu\text{m}$  that corresponds to the microfocusing region. The 3D intensity distributions for RGB colors are shown in Fig. 6b. They are similar to the calculated distributions in Fig. 4. In difference, they have less contrast due to the limited resolution of the microscope objective. The comparison of experimental and calculated  $z$  and  $x$  intensity distributions at the focal point are displayed in Fig. 7 for RGB colors (from left to right). The longitudinal and transverse intensity distributions at the focal point are shown in 1<sup>st</sup> and 2<sup>nd</sup> row, respectively. On this figure, the experimental data have been deconvoluted using an open software package [12].

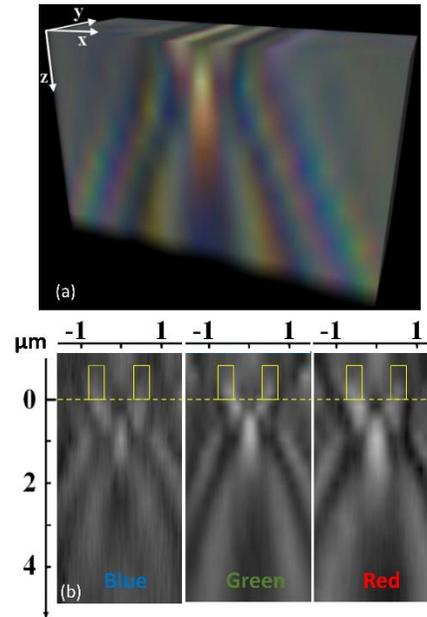


Fig.6. Experimental 3D intensity distribution below the diffractive polymer microlines.

The experimental microlens characteristics are summarized in Table 2. They are in good agreement with the calculated characteristics in Table 1. The experimental focal lengths and depths of focus for a non-polarized light correspond within 10% with the simulated ones for the averaged polarization. However, for the lateral resolutions that are about two times smaller than the wavelength, the deconvolution procedure is less efficient that leads to overestimated experimental values for the green and red wavelengths.

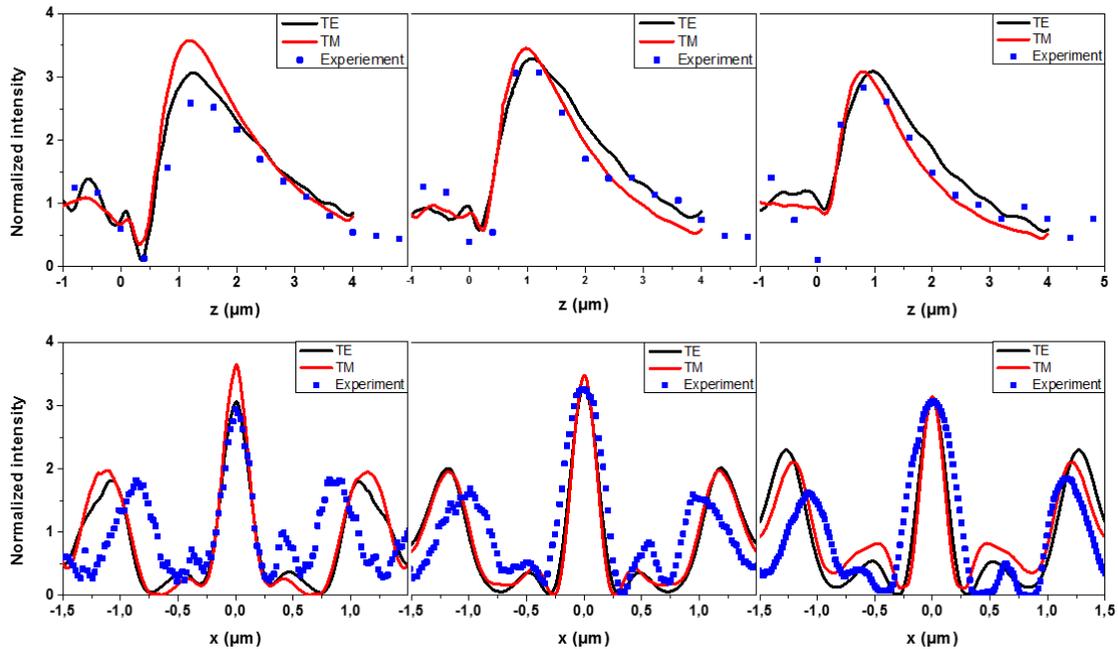


Fig. 7. First and second rows: intensity distributions along the longitudinal focal axis ( $x = 0, z$ ), and intensity distributions along the lateral focal axis ( $x, z = z_f$ ). Solid black and red lines represent TE and TM polarization for simulations. Dotted lines for experimental data after deconvolution. Left, middle and right columns are for blue, green and red color splitting, respectively.

**Table 2**

**Experimental optical characteristics.  $Z_f$ , FWHM<sub>x</sub>, FWHM<sub>z</sub> and  $I_{max}/I_0$  that are respectively the focal length, the lateral resolution, the depth of focus and the normalized intensity at the focal point.**

	Wavelength ( $\mu\text{m}$ )	$Z_f$ ( $\mu\text{m}$ )	FWHM <sub>x</sub> ( $\mu\text{m}$ )	FWHM <sub>z</sub> ( $\mu\text{m}$ )	$I/I_0$
	Bleu 0.45	1.3	0.29	2.10	2.9
Experiment	Green 0.53	1.0	0.38	1.83	3.4
	Red 0.60	0.8	0.44	1.71	3.1

#### 4. Conclusions

We report on the design of a diffractive microlens based on pair of parallel polymer microlines separated by 1.12  $\mu\text{m}$ . 2D-FEM simulations show that diffraction of an incident plane-wave by the line pair leads to a diffraction-limited focusing when their cross-section geometry is optimized, i.e. rectangular width  $W = 0.40 \mu\text{m}$  and height  $H = 0.80 \mu\text{m}$  for a refractive index  $n=1.5$ . The experimental demonstration has been done with microlines fabricated by two-photon polymerization on a glass substrate. The experimental optical characteristics are in good agreement with simulation results: focal distance  $Z_f \approx 1 \mu\text{m}$ , lateral resolution  $\text{FWHM}_x \approx 0.4 \mu\text{m}$  (limited by the optical resolution), depth of focus  $\text{FWHM}_y \approx 2 \mu\text{m}$ ; and the maximum normalized intensity at focus  $I_{max}/I_0 \approx 3$ .

Further calculations indicates that this type of diffraction focusing is resistant with downsizing the pixel size in the sub-micron regime. The ongoing experimental demonstration will be reported later. In addition, ongoing work on microlens arrays, and phase zone plate based on such diffractive effects show that the focusing resolution improves with the number of diffractive elements due to their content of higher spatial frequencies.

#### Annex 1:

We acknowledge the fabrication of microlines by Safi Jradi (Institut Charles Delaunay, Université de Technologie de Troyes) using NanoMat platform with the following process.

The photopolymerizable formulation consisted of 1 wt. % photo-initiator (IRG819, commercialized by Ciba, now BASF) mixed with pentaerythritol triacrylate (PETA) which has been demonstrated suitable for 3D nanofabrication by two photon polymerization (TPP) [10].

A commercial system from Nanoscribe GmbH was used for the sample fabrication. The system is an inverted microscope coupled with a femtosecond pulsed laser emitting at 780 nm wavelength. An oil immersion objective (100 $\times$  Zeiss NA=1.3) is used to focus the laser beam into the sample which is mounted on a XYZ positioning stage.

For the sample preparation, a glass substrate (22x22 $\mu\text{m}^2$ ) of  $\sim 170 \mu\text{m}$  thickness was glued on the sample holder. Then a photopolymer drop was directly deposited on the glass substrate. The writing system is equipped with an automatic interface finder camera that allows automatic positioning of the focus with respect to the interface between glass substrate and photopolymer. The slice distance was 0.05  $\mu\text{m}$  in x and 0.10  $\mu\text{m}$  in z. These values were defined by considering the size of polymer voxel when the incident energy dose is close to the energy threshold of TPP. In order to optimize the lines dimensions, different values of laser power (5,6 and 7 mW) were tested with a writing speed of 100  $\mu\text{m/s}$ .

#### Acknowledgements

Dr. P.L. Baldeck acknowledges the support by the European Union's Horizon 2020 research and innovation program through PHENOMENON grant under grant agreement n° 780278. PHENOMENON project is an initiative of the Photonics Public-Private Partnership. Pr. O. Ziane and A. Tellal acknowledge the support from the french-algeria PHC Tallissi 2016.

**"We are thankful to the reviewer's recommendations that helped us to precise several important statements of the manuscript."**

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